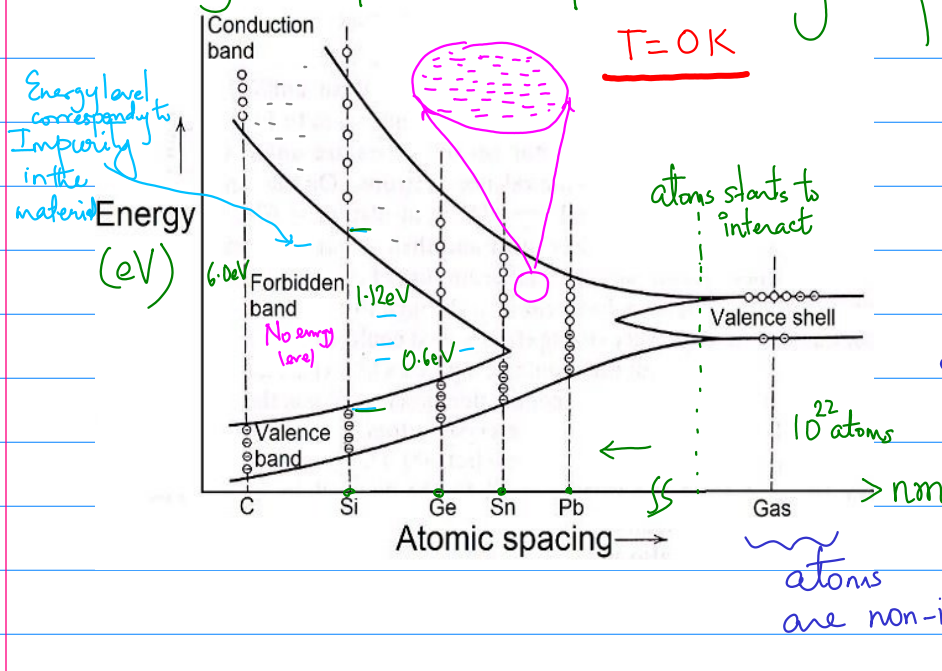


Charge-Carriers density in Semiconductors

Band diagram of the solids of Carbon group (gr. 14) elements:



$$E_g(T) = E_g(0) - \frac{\alpha T^2}{T + \beta}$$

α, β are the parameters.

For Silicon:

- Lets assume it to be 100% pure.

Condition (i): Temperature $T=0K$

at $T=0K$; thermal energy $= k_B T \approx 0$

⇒ all valance electrons remain in the valance band. That is,

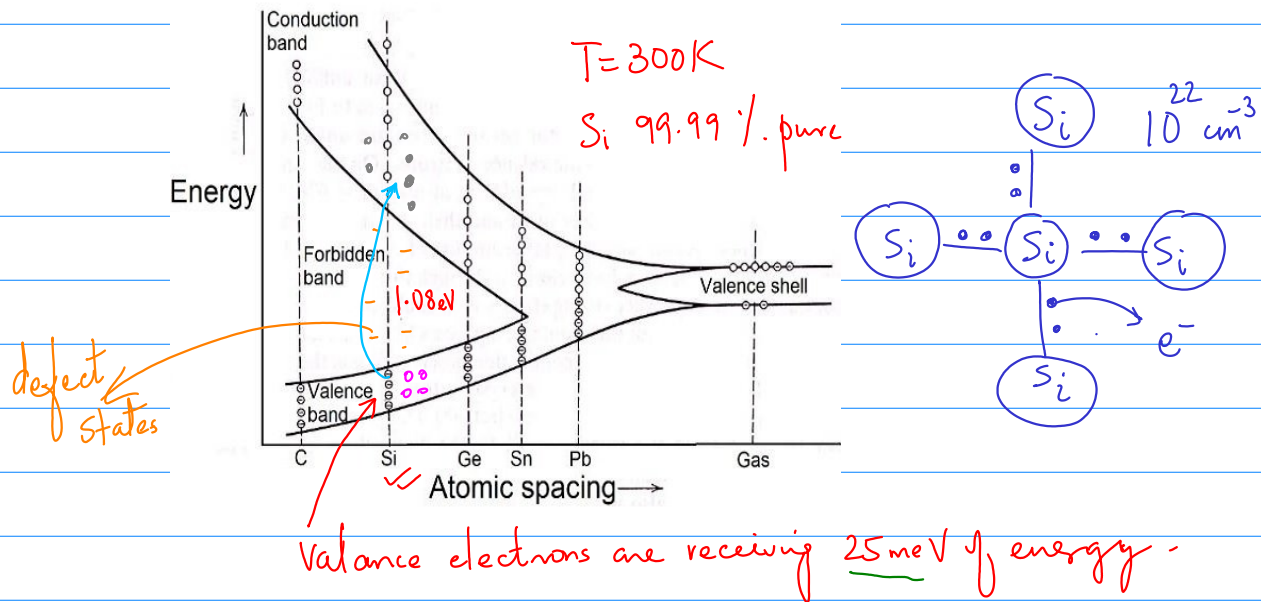
Conduction Band is empty with the electrons.

ie, Intrinsically, No "Free" charge-carriers.

⇒ Intrinsic carrier-density at $T=0$ is "zero".

Condition (ii) $T = 300\text{K}$; we have 99.99% pure Silicon.

$$\text{Thermal Energy} = k_B T \approx \underline{25\text{meV}}$$



at this given condition ;
roughly $\sim 10^{10} \text{ cm}^{-3}$ electrons from the Valence band cross the forbidden band (Energy gap) and populate into the conduction band.

Compare this population w.r.t # silicon atoms

$$\frac{10^{10}}{10^{22} \text{ cm}^{-3}}$$

$$\frac{10^{10}}{10^{22} \text{ cm}^{-3}}$$

\Rightarrow Out of one trillion silicon atoms, only one silicon atom got the chance to release its valance electron to the conduction band.

Intrinsically, there are $\sim 10^{10}$ "FREE" electrons at 300K.

n = electron density (cm^{-3})

p = hole (vacancy) density (cm^{-3})

$$n = p = n_i = 10^{10} \text{ cm}^{-3}$$

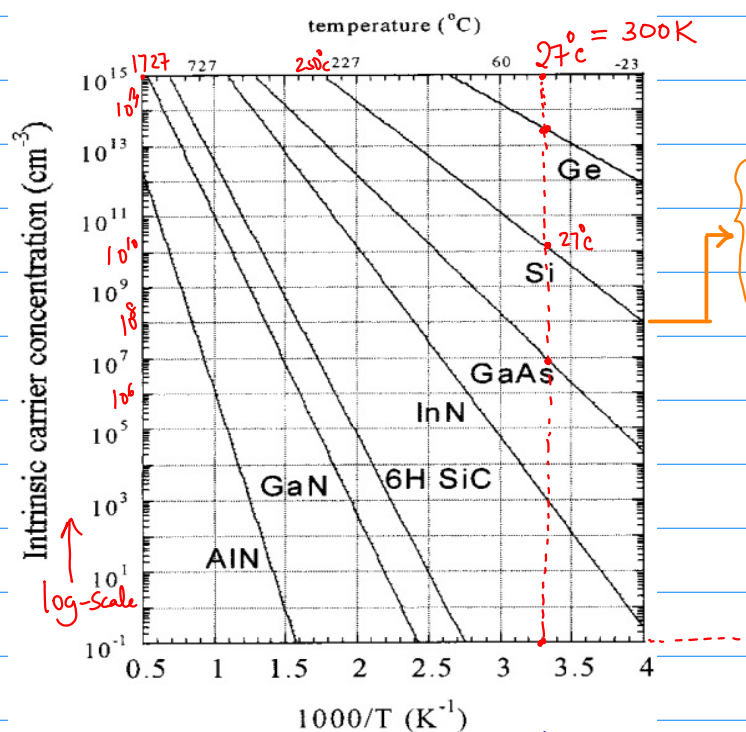
Practical values:

$$n_i(\text{silicon}) = 1.5 \times 10^{10} \text{ cm}^{-3}$$

$$n_i(\text{Germanium}) = 2.4 \times 10^{13} \text{ cm}^{-3}$$

$$n_i(\text{GaAs}) = 1.8 \times 10^6 \text{ cm}^{-3}$$

at
300K



For Silicon,

$$\left. \begin{array}{l} T = -23^\circ\text{C} \\ n_i = 10^8 \text{ cm}^{-3} \end{array} \right\}$$

$$\left. \begin{array}{l} T = 250^\circ\text{C} \\ n_i = 10^{15} \text{ cm}^{-3} \end{array} \right\}$$

In silicon,

\Rightarrow Raising the temperature by a factor of 10, raises the

the n_i by 10^5 cm^{-3} (five orders of magnitude)

On earth, even we are at the place with lowest/highest temperature, the variation in intrinsic carrier density of silicon is not much
ie, it varies b/w 10^9 cm^{-3} to 10^{11} cm^{-3} .

As compared to the ^{"Free"} carrier density in conductors ($\approx 10^{22} \text{ cm}^{-3}$), these are negligible.

Therefore,

\Rightarrow Intrinsically, the semiconductors are insulators.

For practical devices using semiconductor, the density of intrinsic carriers is not sufficient.

\Rightarrow You need to look for the condⁿ, wherein more "free" charge-carriers can be created.

\Rightarrow Needs to tune the carrier-density Extrinsically.

Ques: Why do we need to tune the carrier-density?

$$\sigma_e = e \mu n$$

Conductivity \rightarrow σ_e

electronic charge ($1.6 \times 10^{-19} \text{C}$) \rightarrow e

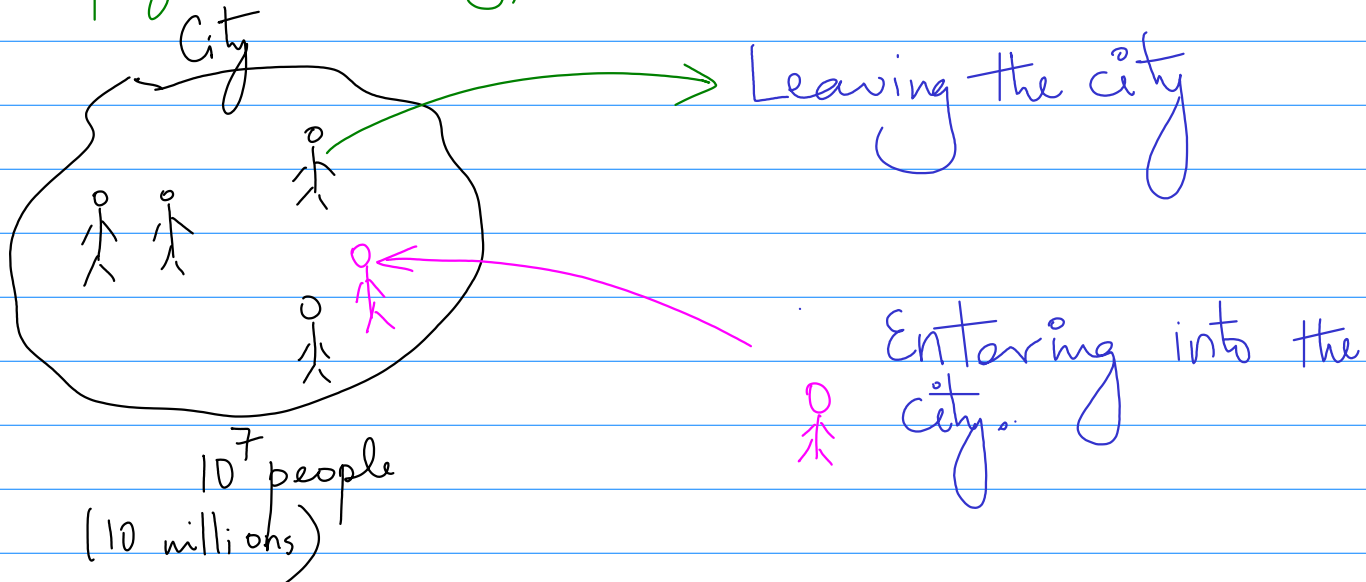
change-carrier mobility \rightarrow μ

change-carrier density (cm^{-3}) \rightarrow n

if we control the electronic density (n) by some extrinsic mean, we can control the conductivity.

Extrinsic Mean \rightarrow DOPING

Doping: An Analogy

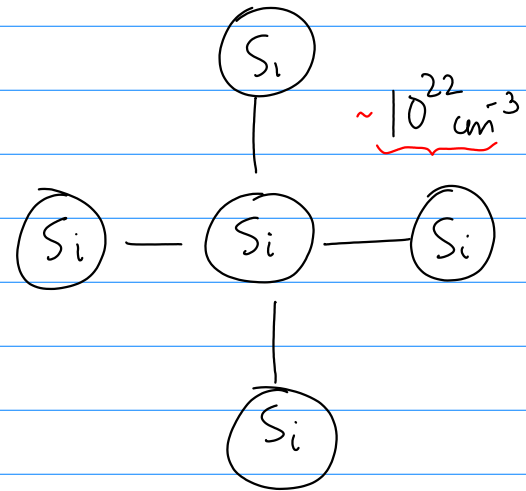


Effectively, out of a population of 10 million people, replacing one person with another will not make any effect on the demography of the city.

Doping of Silicon:

Intrinsic Silicon:

Atomic density $\sim 10^{22} \text{ cm}^{-3}$

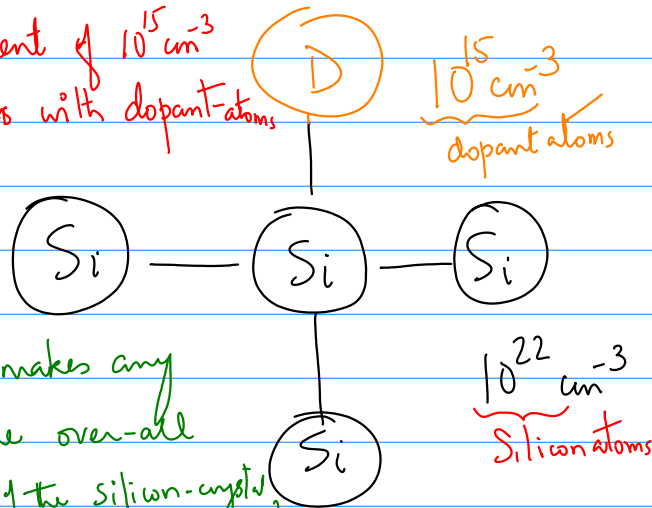


Doping of Silicon:

Atomic density = 10^{22} cm^{-3}

Dopant density: 10^{15} cm^{-3}

Replacement of 10^{15} cm^{-3} Silicon atoms with dopant-atoms



Ques: Will this process of doping makes any change in the over-all properties of the silicon-crystal?

Out of 10^7 Silicon atoms only one Silicon atom is replaced with the Dopant-atom

As a result, one cannot see any change in the mechanical properties of the Silicon.

However, the electronic properties changes. How?

Lets see dopant is a "donor". (Which can donate electron)

$$\text{Si atomic density} = 5 \times 10^{22} \text{ cm}^{-3}$$

$$\text{Donor density} = 1 \times 10^{15} \text{ cm}^{-3}$$

\Rightarrow Out of 5×10^{22} Silicon atoms cm^{-3} ; 1 silicon atom is being replaced with the donor-atom.

\Rightarrow The donor is 20 parts per billion (ppb)

Silicon atoms
of 1 billion
population

\rightarrow 20 atoms are the extrinsic one (donor-atom)

Our focus is the electronic effect :

$$\text{Add } 10^{10} + 10^{15} \text{ cm}^{-3} = 10^{15} \text{ cm}^{-3}$$

$$\sigma = e \mu n$$

Intrinsic Conductivity $\sigma_i = e \mu n_i$

Extrinsic conductivity (due to doping) $\sigma_{ex} = e \mu n_D$

$$\left\{ n = p = n_i = 10^{10} \text{ cm}^{-3} \right\}$$

$$n_D = \text{Dopant density cm}^{-3} = 10^{15} \text{ cm}^{-3}$$

$$\text{Ratio of conductivities} = \frac{\sigma_{ex}}{\sigma_i} = \frac{\cancel{\mu} N_D}{\cancel{\mu} N_i} = \frac{10^{15} \text{ cm}^{-3}}{10^{10} \text{ cm}^{-3}} = 10^5$$

$$\sigma_{ex} = 10^5 \sigma_i$$

⇒ Conductivity of the Silicon enhances by five Order of magnitude.

Analogy: Wallet is having Rs. 100.

if it is enhanced with five order of magnitude

$$\text{Rs } 100 \cdot 10^5 = \text{Rs } 10^7 = \text{Rs } 10 \text{ million.} \\ = \text{Rs } 1 \text{ Crore}$$

Two kinds of dopants:

1) Donors: Releasing electrons \equiv n-type semiconductors

2) Acceptors: Accepting electrons (Releasing holes) \equiv p-type semiconductors

Donors \rightarrow Pentavalent elements P, As, Sb (Antimony)

Acceptors - Trivalent elements B, Al, Ga, In ...

⇒ What would be the distribution of "FREE" charge carriers in CB & VB?